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(71) Applicant (for all designated States except US): KONIN-KLIJKE PHILIPS ELECTRONICS N.V. [NL/NL]; Groenewoudseweg 1, NL-5621 BA Eindhoven (NL).

(72) Inventors; and

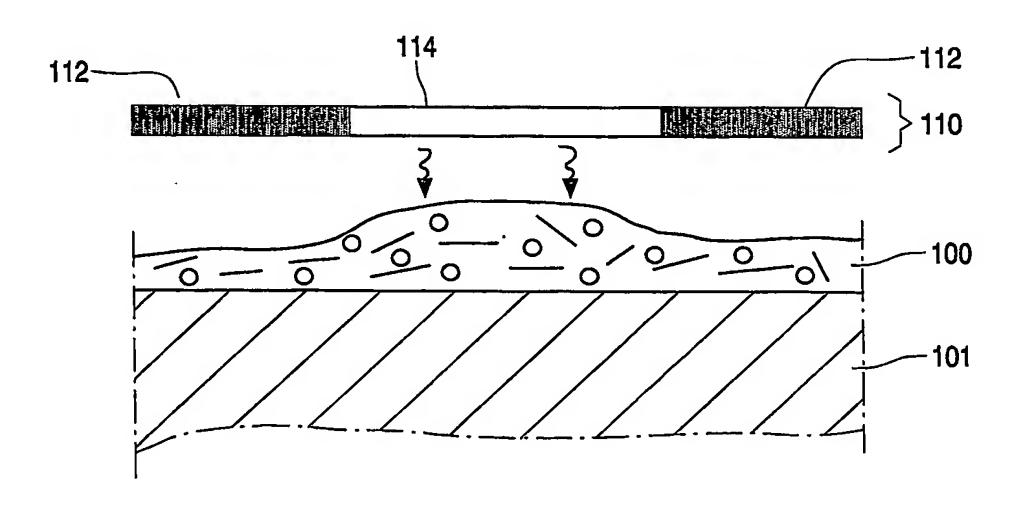
(75) Inventors/Applicants (for US only): BROER, Dirk, J. [NL/NL]; c/o Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL). WITZ, Christiane, M., R. [BE/NL]; c/o Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL). VAN BOMMEL,

Ties [NL/NL]; c/o Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL).

- (74) Agent: ELEVELD, Koop, J.; Prof. Holstlaan 6, NL-5656 AA Eindhoven (NL).
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(54) Title: METHOD OF MANUFACTURING A REFLECTOR, AND LIQUID CRYSTAL DISPLAY DEVICE INCLUDING SUCH A REFLECTOR



(57) Abstract: The invention relates to a method for manufacturing a diffusive reflector (450) for a reflective or transflective Liquid Crystal Display (400). The reflector comprises a surface (452) that is structured by means of a photo-embossing process. Herein, a layer (100) of a mixture is provided including a photo-diffusible monomer (102), which may be transported through the layer under the influence of selectively applied irradiation. A layer relief is thus formed, which is preferably developed further at an elevated temperature. The layer is fixed and stabilized by means of a cross-linking step, preferably including thermally induced and/or photo-induced polymerization. In a final step, the polymer relieved surface thus formed is provided with a reflective material (154).

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